

L Number	Hits	Search Text	DB	Time stamp
1	2170	(etch\$3 remov\$3) near5 pad adj oxide	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/10 14:44
2	347	((etch\$3 remov\$3) near5 pad adj oxide) same trench adj2 isolation	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/10 14:45
3	211	(((etch\$3 remov\$3) near5 pad adj oxide) same trench adj2 isolation) same oxide near5 trench	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/10 14:45
4	71	(((etch\$3 remov\$3) near5 pad adj oxide) same trench adj2 isolation) same oxide near5 trench) same silicon adj nitride	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/10 14:45
5	29	((((etch\$3 remov\$3) near5 pad adj oxide) same trench adj2 isolation) same oxide near5 trench) same silicon adj nitride) and @ad<19991015	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/10 14:46